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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/501,124	02/09/2000	Gabriela Brase	00P7456US	3427
75	90 01/28/2003			
Siemens Corporation			EXAMINER	
186 Wood Aver			GURLEY, LYNNE ANN	
Iselin, NJ 08830			ART UNIT	PAPER NUMBER
			2812	
			DATE MAILED: 01/28/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

Application No. 09/501,124

Applicant(s)

Brase

Office Action Summary Examiner

Lynne Gurley

Art Unit 2812



The MAILING DATE of this communication appears on the cover sheet with the correspondence address					
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET THE MAILING DATE OF THIS COMMUNICATION.	 				
 Extensions of time may be available under the provisions of 37 CFR 1.136 (a). I mailing date of this communication. 	n no event, however, may a reply be timely filed after SIX (6) MONTHS from the				
 If the period for reply specified above is less than thirty (30) days, a reply within If NO period for reply is specified above, the maximum statutory period will apply 	and will expire SIX (6) MONTHS from the mailing date of this communication.				
 Failure to reply within the set or extended period for reply will, by statute, cause Any reply received by the Office later than three months after the mailing date of earned patent term adjustment. See 37 CFR 1.704(b). 					
Status					
1) X Responsive to communication(s) filed on Oct 30,	2002 .				
2a) ☐ This action is FINAL . 2b) ☑ This ac	ction is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.					
Disposition of Claims					
4) X Claim(s) 1-12 and 24-29	is/are pending in the application.				
4a) Of the above, claim(s) 24-29	is/are withdrawn from consideration.				
5) Claim(s)	is/are allowed.				
6) 💢 Claim(s) <u>1-12</u>	is/are rejected.				
7) Claim(s)	is/are objected to.				
8) Claims	Claims are subject to restriction and/or election requiremen				
Application Papers					
9) \square The specification is objected to by the Examiner.					
D)☐ The drawing(s) filed on is/are a)☐ accepted or b)☐ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examine					
If approved, corrected drawings are required in reply to this Office action.					
12) \square The oath or declaration is objected to by the Exam	niner.				
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgement is made of a claim for foreign	priority under 35 U.S.C. § 119(a)-(d) or (f).				
a) \square All b) \square Some* c) \square None of:					
1. \square Certified copies of the priority documents ha	ve been received.				
2. Certified copies of the priority documents ha	ve been received in Application No				
3. Copies of the certified copies of the priority application from the International Bur *See the attached detailed Office action for a list of t					
14) Acknowledgement is made of a claim for domesti					
a) The translation of the foreign language provision					
15)☐ Acknowledgement is made of a claim for domesti					
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper No(s).				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application (PTO-152)				
3) Information Disclosure Statement(s) (PTO-1449) Paper No(s).	6) Other:				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The rejection of claims 13, 15, 18-19 and 21-23 under 35 U.S.C. 102(e) as being anticipated by Liu et al. (US 6,326,300, dated 12/4/2001, filed 9/21/1998) has been overcome by the amendment submitted 10/30/02.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - 3. Resolving the level of ordinary skill in the pertinent art.
 - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

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4. Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al. (US 6,326,300, dated 12/4/2001, filed 9/21/1998) in view of Jang (US 6,265,319, dated 7/24/2001, filed 9/1/1999).

Liu shows the method substantially as claimed in figures 1-8 and corresponding text, with conductive regions 11 (column 6, lines 64-67), first layer 10, interlevel dielectric 12, etch stop 14, via patterning (fig. 2), trench dielectric 22, etching of the trench and vias (fig 6) and conductive material 30. Note that it is considered inherent that if a spin-on-polymer were used, a spin-on technique followed by a curing process would be in order. Additionally, Liu teaches that the material of the interlevel dielectric and trench dielectric may be the same or different; that a spin-on polymer may be used; and that the etch stop layer is between 100 nm and 250 nm thick (column 7, lines 42-44).

Liu lacks anticipation only in not teaching that the etch stop may be a polymer with a low dielectric constant (column 1, lines 40-44), even though Liu does teach that the etch stop may be made of any material which resists etching during the interlevel dielectric and trench dielectric etching. Liu also lacks anticipation in not teaching that: 1) the polymer may be polyorylene-ether (FLARE) or polybenzoxazole; 2) a cap layer is formed; 3) and a hard mask is used.

Jang teaches that a polymer such as FLARE may be used as an etch stop layer between two low dielectric constant layers in a dual damascene technique.

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It would have been obvious to one of ordinary skill in the art to have used FLARE for the

etch stop layer in the method of Liu with the motivation that FLARE would possess suitable etch

resistant properties while etching the appropriate dielectric layers.

It would have been obvious to one of ordinary skill in the art to have formed a cap layer

and a hard mask in order to improve oxidation resistance and etching profiles during exposure of

the device between processing and during lithographical techniques.

Response to Arguments

5. Applicant's arguments with respect to claims 1-12 have been considered but are moot in

view of the new ground(s) of rejection.

a. Upon reviewing the amended case, the Examiner has made this second action non-final

due to the error of not including the claims 1-12 in the previous rejection, although these claims

were correctly notated on the office action summary as being rejected. The non-final rejection of

this instant office action includes the claims 1-12 as they were meant to be rejected in the previous

office action.

Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Lynne A. Gurley whose telephone number is (703) 305-3474. The examiner

can normally be reached on Monday-Friday from 7:30 AM to 4:00 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John F. Niebling, can be reached on (703) 308-3325. The fax phone number for the organization where this application or proceeding is assigned is 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 308-0956.

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January 27, 2003

LYNNE GURLEY
PATENT EXAMINER
Art Wint 1812

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